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## A quadruple-band metal–nitride nanowire artificial photosynthesis system for high efficiency photocatalytic overall solar water splitting†

Yongjie Wang,<sup>a</sup> Yuanpeng Wu,<sup>a</sup> Kai Sun<sup>b</sup> and Zetian Mi<sup>\*a</sup>

Photocatalytic water splitting is a wireless method for solar-to-hydrogen conversion. To date, however, the efficiency of photocatalytic water splitting is still very low. Here, we have investigated the design, synthesis, and characterization of quadruple-band InGa<sub>N</sub> nanowire arrays, which consist of In<sub>0.35</sub>Ga<sub>0.65</sub>N, In<sub>0.27</sub>Ga<sub>0.73</sub>N, In<sub>0.20</sub>Ga<sub>0.80</sub>N, and GaN segments, with energy bandgaps of ~2.1 eV, 2.4 eV, 2.6 eV, and 3.4 eV, respectively. Such multi-band InGa<sub>N</sub> nanowire arrays are integrated directly on a nonplanar wafer for enhanced light absorption. Moreover, a doping gradient is introduced along the lateral dimension of the nanowires, which forms a built-in electric field and promotes efficient charge carrier separation and extraction for water redox reactions. We have demonstrated that the quadruple-band InGa<sub>N</sub> nanowire photocatalyst can exhibit a solar-to-hydrogen efficiency of ~5.2% with relatively stable operation. This work demonstrates a novel strategy using multi-band semiconductor nanostructures for artificial photosynthesis and solar fuel conversion with significantly improved performance.

Photocatalytic water splitting is a wireless approach to convert solar energy directly to hydrogen fuels, which is an essential step of artificial photosynthesis.<sup>1–4</sup> Unlike photoelectrochemical water splitting that generally requires the integration of two (photo)electrodes in a highly conductive electrolyte, water redox reactions can occur on the same surfaces of a light absorber in photocatalytic overall water splitting in nearly pH neutral solutions,<sup>4–6</sup> such as pure water or seawater, thereby promising large scale practical application. Direct photocatalytic water splitting has stringent requirements on the electronic band structures of the semiconductor light absorbers:<sup>5,7</sup> the conduction and valence band edges must straddle water redox potentials with sufficient chemical overpotentials for proton reduction and water

### Conceptual insights

Photocatalytic overall water splitting has been considered as one of the most promising approaches of renewable energy production and environmental remediation, which can perform one-step dissociation of water in nearly pH neutral solution. To date, however, the best reported solar-to-hydrogen conversion efficiency for pH neutral photocatalytic water splitting is generally limited to 1–3%, or less, mainly due to insufficient solar absorption and charge carrier separation. In this work, we have investigated the design, synthesis, and characterization of quadruple-band InGa<sub>N</sub> nanowire arrays for high efficiency overall solar water splitting, which can harvest solar photons in the entire visible spectrum. Significantly, InGa<sub>N</sub> nanowires are characterized by the presence of well-defined anode and cathode surfaces for water oxidation and proton reduction, respectively, which enables precise control of charge carrier flow at the nanoscale. The spatially separated electron and the hole gas significantly minimize surface and bulk recombination and suppress back reactions, which have been some of the major challenges for achieving efficient photocatalytic water splitting to date.

oxidation reactions, respectively,<sup>8–10</sup> while the energy bandgap should be sufficiently narrow for efficient sunlight harvesting. In spite of intensive studies on photocatalytic water splitting,<sup>6,11–15</sup> most of the semiconductor light absorbers reported to date do not possess suitable band edge positions for overall water splitting under visible light illumination.<sup>16–18</sup> For example, metal oxides, such as TiO<sub>2</sub>, In<sub>2</sub>NiTaO<sub>4</sub>, SrTiO<sub>3</sub>, GaN/ZnO, and LaMgTaO<sub>2</sub>,<sup>14,19–23</sup> can only absorb a small part of the solar spectrum due to their large bandgaps, whereas narrow bandgap semiconductors, such as Si, GaAs, and InP,<sup>24–26</sup> do not possess suitable band edge positions to drive overall water splitting. Intensive studies have been performed to extend the energy bands of various wide bandgap materials to enhance the efficiency of photocatalytic solar water splitting, such as the utilization of black TiO<sub>2</sub> by metal doping, dye sensitization, or adding surface hydroxyl groups, but with limited success.<sup>27–31</sup> To date, the solar-to-hydrogen (STH) conversion efficiency is generally limited to <0.5% for single-band metal-oxide photocatalysts (see the ESI,† Table S1). An STH

<sup>a</sup> Department of Electrical Engineering and Computer Science, University of Michigan, 1301 Beal Avenue, Ann Arbor, Michigan 48109, USA.  
E-mail: ztmi@umich.edu

<sup>b</sup> Department of Materials Science and Engineering, University of Michigan, 2300 Hayward Street, Ann Arbor, Michigan 48109, USA

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efficiency up to 5% has been reported with the use of  $\text{CoO}_x$  nanoparticles but the stability is limited to  $\sim 30$  min.<sup>4</sup> Z-scheme photocatalytic systems using two-step photo-excitation, in principle, can overcome the unsuitable energy band structures for water redox reactions. For example,  $\text{SrTiO}_3/\text{BiVO}_4$  has been studied for improved photocatalytic performance.<sup>11,32</sup> However, the energy conversion efficiency is still limited to  $\sim 1\%$  (see the ESI,† Table S1).

Recently, metal–nitride semiconductors, *e.g.*,  $\text{In}_x\text{Ga}_{1-x}\text{N}$  (noted as InGaN), have drawn significant attention for photocatalytic water splitting.<sup>33–38</sup> The energy gap of InGaN materials can be continuously varied from ultraviolet, through the visible region, to the near-infrared region, covering nearly the entire solar spectrum. Significantly, the energy band edge positions of InGaN materials can straddle water redox potentials for a large range of alloy compositions (up to indium compositions of  $\sim 40\text{--}50\%$ ), which corresponds to an energy bandgap of  $\sim 1.7\text{--}2$  eV.<sup>39–41</sup> GaN-based materials have also been widely used in electronics and photonics industries, being the 2nd most produced semiconductors (next to only silicon).<sup>42</sup> Since the first demonstration of photocatalytic overall water splitting on GaN nanostructures, significantly improved performance has been reported by engineering the surface charge properties through p-type dopant incorporation and surface Fermi level tuning.<sup>30,43,44</sup> The wide bandgap ( $\sim 3.4$  eV) of GaN, however, greatly limits its light absorption capacity only in the ultraviolet region. To enhance its visible light absorption, InGaN can be integrated forming a double-band structure as demonstrated previously.<sup>33,45</sup> In addition, the Mg doping gradient in III-nitride nanostructures can form a built-in electric field facilitating charge carrier separation and extraction.<sup>34,41</sup> Recently, photocatalytic overall water splitting with an STH efficiency up to 3.3% has been demonstrated with the use of double-band InGaN/GaN nanowire structures.<sup>33,34</sup> However, in these studies, the indium composition is limited to  $\sim 22\%$  or less, corresponding to an energy gap  $> 2.6$  eV, which can only absorb photons in the blue spectrum. Albeit photocatalytic water splitting with photon absorption up to 560 nm has been reported for InGaN nanowire photocatalysts,<sup>46,47</sup> the reported efficiency is still very low, largely due to the inefficient separation and extraction of photo-generated charge carriers.

In this work, we have investigated the design and performance of multi-band InGaN/GaN nanowire arrays for photocatalytic overall pure water splitting. The monolithically integrated quadruple-band InGaN nanowire photocatalyst consists of Mg-doped (p-type)  $\text{In}_{0.35}\text{Ga}_{0.65}\text{N}$  ( $E_g \sim 2.1$  eV),  $\text{In}_{0.27}\text{Ga}_{0.73}\text{N}$  ( $E_g \sim 2.4$  eV),  $\text{In}_{0.20}\text{Ga}_{0.80}\text{N}$  ( $E_g \sim 2.6$  eV) and GaN ( $E_g \sim 3.4$  eV) segments, which were grown on nonplanar silicon wafers by plasma-assisted molecular beam epitaxy (MBE) and can effectively absorb the ultraviolet and visible portion of the solar spectrum. The use of a nonplanar Si wafer allows for the controlled formation of an Mg doping gradient along the lateral dimension of the nanowire structure. The resulting built-in electric field steers photo-generated electrons and holes to the proton reduction and water oxidation sites, respectively, thereby leading to more efficient charge carrier separation and suppressed recombination and back reaction.

An STH conversion efficiency of  $\sim 5.2\%$  was achieved on such quadruple-band InGaN nanowire photocatalysts. The artificial photosynthesis device presented in this study offers a unique platform for achieving high efficiency, scalable solar-to-fuel conversion, including solar water splitting and reduction of carbon dioxide ( $\text{CO}_2$ ) to hydrocarbon fuels.

Illustrated in Fig. 1a is the schematic conduction and valence band edge positions of GaN,  $\text{In}_{0.4}\text{Ga}_{0.6}\text{N}$ , and InN, and their respective alignments to the water redox potentials, represented by the hydrogen evolution reaction (HER) and the oxygen evolution reaction (OER) in pH neutral water solution.<sup>48–50</sup> It is seen that InGaN alloys with indium compositions up to  $\sim 40\%$  can meet the stringent electronic and thermodynamic requirements for overall water splitting and therefore have the potential to drive solar water splitting in pH neutral electrolyte solutions without sacrificial reagents.<sup>49,50</sup> The overall photocatalytic water splitting system presented in this study is illustrated in Fig. 1b, showing the monolithic integration of InGaN nanowire arrays on a nonplanar silicon wafer. A schematic of the ideal configuration for the quadruple-band InGaN nanowire structure and the light splitting diagram is further depicted in Fig. 1c. Indium compositions in each band are 0%,  $\sim 20\%$ ,  $\sim 27\%$ , and  $\sim 35\%$  in this study, corresponding to energy bandgaps of  $\sim 3.4$  eV,  $\sim 2.6$  eV,  $\sim 2.4$  eV, and  $\sim 2.1$  eV, respectively, which could absorb solar photons with wavelengths up to  $\sim 600$  nm. For comparison, previously reported photocatalytic devices can only absorb high energy photons (2.8–3.5 eV) for overall water splitting,<sup>41,51,52</sup> which limits their energy conversion efficiencies. In addition, the use of a nonplanar wafer in this work offers several benefits. This leads to enhanced light trapping and absorption,<sup>53,54</sup> and allows for the direct exposure of lateral surfaces of nanowire arrays to normal sunlight illumination. As such, an inverted multi-band structure is studied, with the narrower bandgap light absorber placed atop. Schematically shown in Fig. 1d is the monolithically integrated quadruple-band  $\text{In}_{0.35}\text{Ga}_{0.65}\text{N}/\text{In}_{0.27}\text{Ga}_{0.73}\text{N}/\text{In}_{0.20}\text{Ga}_{0.80}\text{N}/\text{GaN}$  nanowire structure used for photocatalytic overall water splitting in this study. Such a stacking sequence was found to be easier to grow by plasma-assisted MBE (see Methods).

Significantly, due to the use of a nonplanar Si wafer and the formation of nanowires vertically aligned to the local surfaces (Fig. 1b), only one side of the nanowires is directly exposed to Mg doping flux during nanowire epitaxial growth, as schematically shown in Fig. 1d. As such, an Mg doping gradient is spontaneously formed along the nanowire lateral dimension, which introduces a built-in electric field, as shown in Fig. 1e.<sup>34</sup> It is seen that photo-generated electrons migrate towards the lightly Mg-doped side for the proton reduction reaction, whereas photo-generated holes drift to the more heavily Mg-doped surface for the water oxidation reaction. The rapid separation and extraction of photo-generated electrons and holes to the respective cathodic and anodic surfaces can significantly reduce charge carrier recombination and further suppress any back reaction, thereby leading to enhanced efficiency for solar water splitting.<sup>55–58</sup>



**Fig. 1** Schematic design and structural properties of monolithic multi-band metal nitride nanowire arrays for photocatalytic overall water splitting in nearly pH neutral electrolyte solution. (a) Band edge positions of GaN, InN, and their InGaN compounds. In liquid solution at pH ~ 7, InGaN alloys with indium incorporation up to 40% can straddle the water redox reaction, noted as Region 2. Higher indium incorporation (Region 1) makes InGaN compounds unsuitable for overall solar water splitting. (b) Schematic illustration of photocatalytic water splitting on InGaN nanowire arrays monolithically integrated on a nonplanar Si wafer. (c) Schematic illustration of the ideal configuration for light absorption on the multi-band InGaN stacks with varied indium compositions. (d) Schematic of the quadruple-band InGaN nanowire. The p-type dopant originating from the tilted Mg effusion cell (relative to the nanowire orientation) leads to the Mg doping gradient profile in the lateral direction of the nanowire, which can introduce a built-in electric field, illustrated in (e), for efficient charge carrier separation and extraction for water redox reactions.



**Fig. 2** Properties and photocatalytic performance of single-band metal nitride nanowires grown on planar or nonplanar Si wafers, with different doping levels by varying the Mg effusion cell temperature. Electron microscopy images of InGaN nanowires grown on planar and nonplanar Si wafers. (a) Scale bar: 1  $\mu\text{m}$ . (b) Scale bar: 1  $\mu\text{m}$ . (c) Room-temperature photoluminescence (PL) spectrum of single-band InGaN nanowires with varied indium compositions of ~20%, ~27%, and ~35%, corresponding to an energy gap of ~2.6 eV, ~2.4 eV, and ~2.1 eV, respectively. (d–f) Summarized  $\text{H}_2$  gas production by photocatalytic pure water splitting on single-band p- $\text{In}_{0.20}\text{Ga}_{0.80}\text{N}$  (d), p- $\text{In}_{0.27}\text{Ga}_{0.73}\text{N}$  (e), and p- $\text{In}_{0.35}\text{Ga}_{0.65}\text{N}$  (f) nanowires at varied Mg effusion cell temperatures on planar (blue bars) and nonplanar (red bars) Si wafers.  $\text{H}_2$  gas production was recorded after 40 minutes of the water splitting experiment. The sample sizes are ~2.5–3  $\text{cm}^2$ .

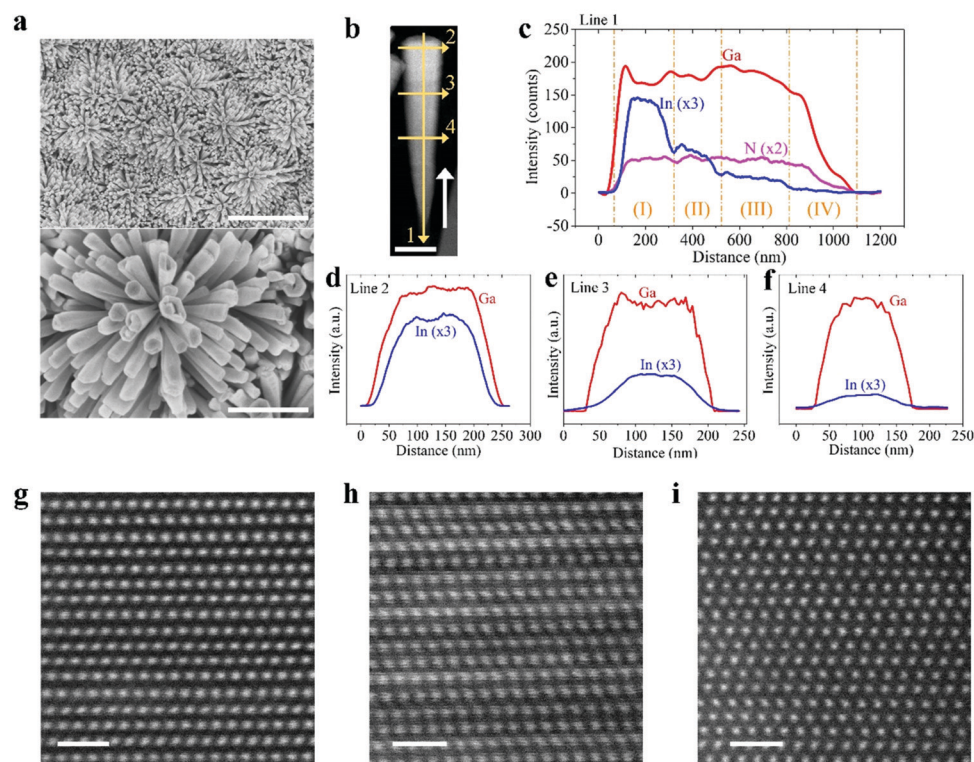


Scanning electron microscopy (SEM) images of metal-nitride nanowires grown on planar and nonplanar Si wafers are shown in Fig. 2a and b, respectively. The InGaN nanowires grown on a nonplanar Si wafer improve the hydrophilic property, as shown in the ESI,† Fig. S1, which may promote more efficient mass diffusion during solar water splitting. Strong photoluminescence (PL) emission spectra of single-band InGaN nanowires with various indium compositions were measured at room temperature, as shown in Fig. 2c, confirming the excellent material quality. By varying the growth conditions (see Methods), their energy bandgaps can be tuned from  $\sim 3.4$  eV to  $\sim 2.1$  eV, corresponding to PL emission wavelengths from  $\sim 370$  nm to  $\sim 580$  nm, respectively.<sup>39,59,60</sup> For the PL emission at  $\sim 580$  nm, the corresponding indium composition is  $\sim 35\%$  (see the ESI,† Fig. S2).<sup>42</sup>

We have first performed photocatalytic water splitting studies on individual single-band InGaN nanowire photocatalysts with varied indium compositions and Mg-dopant incorporations (see Methods). The photocatalytic water splitting performance of p-In<sub>0.20</sub>Ga<sub>0.80</sub>N, p-In<sub>0.27</sub>Ga<sub>0.73</sub>N, and p-In<sub>0.35</sub>Ga<sub>0.65</sub>N, respectively, is summarized as shown in Fig. 2d–f, where samples with areal sizes  $\sim 2.5$ – $3$  cm<sup>2</sup> were used to optimize the doping condition. Recent studies suggest that Mg doping plays a critical role in the photocatalytic performance of

III-nitride materials for overall solar water splitting.<sup>30,61</sup> Therefore, we have firstly investigated and optimized the Mg doping effect on solar hydrogen gas production by varying the Mg doping flux (controlled by the Mg effusion cell temperature). The optimum Mg cell temperatures were identified to be  $\sim 265$  °C,  $260$  °C, and  $250$  °C for In<sub>0.20</sub>Ga<sub>0.80</sub>N, In<sub>0.27</sub>Ga<sub>0.73</sub>N, and In<sub>0.35</sub>Ga<sub>0.65</sub>N nanowire photocatalysts, respectively. An optimum level of Mg dopant concentration is required to minimize the surface band bending for the efficient extraction of photo-generated charge carriers, as reported previously.<sup>30,34,61</sup> The optimum Mg doping levels, however, depend on indium composition and growth conditions (see Methods). In addition, a 20–40% higher hydrogen production rate was measured for InGaN photocatalysts grown on nonplanar Si wafers compared to those on planar Si wafers under optimized conditions, due to, in part, the enhanced charge carrier separation and extraction (Fig. 1e).

We have subsequently studied quadruple-band metal-nitride nanowire photocatalysts by monolithically integrating p-In<sub>0.35</sub>Ga<sub>0.65</sub>N, p-In<sub>0.27</sub>Ga<sub>0.73</sub>N, and p-In<sub>0.20</sub>Ga<sub>0.80</sub>N together on the p-GaN segment (see Fig. 1d), which can absorb incident light with wavelengths up to  $\sim 600$  nm. Shown in Fig. 3a are the SEM images of quadruple-band InGaN nanowires grown on a nonplanar Si substrate. The flower-shaped morphology of



**Fig. 3** Structural characterization of the quadruple-band InGaN nanowire arrays monolithically integrated on a nonplanar Si wafer. (a) Top-view scanning electron microscopy (SEM) images of the flower-shaped InGaN nanowire structure grown on nonplanar Si substrates. Scale bar:  $5\ \mu\text{m}$  (top) and  $1\ \mu\text{m}$  (bottom). (b) Dark-field scanning transmission electron microscopy (DF-STEM) image of the quadruple-band InGaN nanowire, with energy-dispersive X-ray spectroscopy (EDX) line scanning showing the variation of Ga  $L\alpha$ , In  $L\alpha$ , and N  $K\alpha$  characteristic signals along the axial and lateral directions. Scale bar:  $200\ \text{nm}$ . Spectra of Line 1 (c), Line 2 (d), Line 3 (e), and Line 4 (f) are measured along Arrow 1, Arrow 2, Arrow 3, and Arrow 4 in (b), respectively. (g–i) Atomic resolution STEM images of InGaN crystals for (g) In<sub>0.35</sub>Ga<sub>0.65</sub>N, (h) In<sub>0.27</sub>Ga<sub>0.73</sub>N, and (i) In<sub>0.20</sub>Ga<sub>0.80</sub>N segments, respectively. Scale bar:  $1\ \text{nm}$ .

InGaN nanostructures can maximize the side surface exposed to incident light illumination. The multi-band InGaN nanowires were further characterized by scanning transmission electron microscopy (STEM) and energy-dispersive X-ray (EDX) spectroscopy. As shown in Fig. 3b, the brighter contrast in the top region of the nanowire indicates more indium incorporation due to the atomic number contrast nature in high angle annular dark-field (HAADF) imaging. The InGaN nanowire becomes wider in diameter along the growth direction (indicated by the white arrow). EDX line scans were performed along the axial and lateral directions of the InGaN nanowire. Variations in Ga  $L\alpha$ , In  $L\alpha$ , and N  $K\alpha$  characteristic signals are presented in Fig. 3c–f for EDX scans along Line 1, Line 2, Line 3, and Line 4 in Fig. 3b, respectively. Along the axial direction, the In  $L\alpha$  signal intensity gradually decreases, indicating the reduced concentration of In incorporation from top to bottom of the InGaN nanowire, corresponding to the design shown in Fig. 1d. There are four segments forming such quadruple-band InGaN nanowires, including (I)  $\text{In}_{0.35}\text{Ga}_{0.65}\text{N}$ , (II)  $\text{In}_{0.27}\text{Ga}_{0.73}\text{N}$ , (III)  $\text{In}_{0.20}\text{Ga}_{0.80}\text{N}$ , and (IV) GaN. For each InGaN segment, variations in the Ga  $L\alpha$  and In  $L\alpha$  characteristic signals along the nanowire lateral dimensions are measured and shown in Fig. 3d, e, and f, respectively. We have further performed atomic resolution HAADF-STEM imaging for InGaN crystals

with various indium compositions, as shown in Fig. 3g–i. The periodic ordering of atoms further demonstrates the high crystallinity, which is critical to reduce the bulk recombination for efficient charge carrier extraction.

Schematically illustrated in Fig. 4a is the overall solar water splitting process on such quadruple-band InGaN nanowire photocatalysts under light illumination, including photon excitation in each single-band segment, charge carrier separation and extraction, and catalytic water splitting reactions. Due to the built-in electric field introduced by the Mg doping gradient profile, photo-generated electrons and holes are efficiently separated towards the cathodic surface driving the water reduction reaction and the anodic surface driving the water oxidation reaction, respectively.<sup>34,57</sup> Furthermore, ESI,† Fig. S3 demonstrates the separate deposition of Rh and  $\text{CoO}_x$  co-catalyst nanoparticles on the lightly and heavily Mg-doped InGaN surfaces, respectively, which indicates efficient charge carrier separation and extraction due to the Mg doping gradient along the lateral dimension of the nanowires. The rapid separation and extraction of photo-generated electrons and holes to the respective cathodic and anodic surfaces can significantly reduce charge carrier recombination and further suppress any back reaction.<sup>55–58</sup> Shown in Fig. 4b is the PL spectrum of quadruple-band InGaN nanowires measured at room-temperature.



**Fig. 4** Photocatalytic performance of quadruple-band InGaN nanowire arrays measured in pure water by using a 300 W xenon lamp equipped with an AM 1.5G filter. (a) Schematic illustration of the overall water splitting process occurring on the quadruple-band nanowires under light illumination. (b) Room-temperature PL spectrum of the quadruple-band InGaN nanowires, compared to those of single-band nanowires, including (1) p-GaN, (2) p- $\text{In}_{0.20}\text{Ga}_{0.80}\text{N}$ , (3) p- $\text{In}_{0.27}\text{Ga}_{0.73}\text{N}$ , and (4) p- $\text{In}_{0.35}\text{Ga}_{0.65}\text{N}$ . (c)  $\text{H}_2$  and  $\text{O}_2$  gas generation as a function of time measured in multiple cycles.

The very broad emission spectrum indicates its capability of absorbing solar photons across nearly the entire visible spectrum. PL emission spectra of individual InGaN segments are also shown in Fig. 4b for comparison.

Photocatalytic water splitting measurements of the quadruple-band nanowire arrays were performed in pH  $\sim$  7 pure water solution under concentrated light illumination using an AM 1.5G filter (see Methods). Shown in Fig. 4c is the H<sub>2</sub> and O<sub>2</sub> gas evolution for 120 minutes of continuous solar water splitting. Multiple cycles of photocatalytic experiments were further performed to confirm the stable, continuous gas production. The calculated H<sub>2</sub> to O<sub>2</sub> production ratio is nearly 2:1, corresponding to the stoichiometric ratio in water molecules (H<sub>2</sub>O), which is consistent with the overall water splitting reaction occurring without any byproduct.<sup>5</sup> The maximum H<sub>2</sub> generation rate was measured to be  $\sim$ 1840  $\mu\text{mol cm}^{-2} \text{h}^{-1}$  corresponding to an STH efficiency of  $\sim$ 5.2% (see Supplementary Note S1, ESI†).

As summarized in the ESI,† Table S1 is the performance comparison of some previously best-reported photocatalyst systems for overall solar water splitting, compared to the quadruple-band InGaN nanowire photocatalyst demonstrated in this work. To date, for III-nitride semiconductors, the best reported STH efficiency is 3.3% on double-band In<sub>0.22</sub>Ga<sub>0.78</sub>N/GaN photochemical diodes.<sup>34,41,45</sup> For metal oxide and other nitride semiconductors showing comparable photocatalytic stability, *e.g.*, SrTiO<sub>3</sub>, BiVO<sub>4</sub>, and C<sub>3</sub>N<sub>4</sub>,<sup>11,12,32,62–64</sup> the highest STH efficiency has generally been limited to  $\sim$ 1% mainly due to insufficient light absorption and strong recombination. Compared to the previously reported CoO<sub>x</sub> particulate system with  $\sim$ 30 min stability,<sup>4</sup> the presented quadruple-band metal-nitride nanowires demonstrate relatively good stability during overall solar water splitting, without showing any significant degradation of photocatalytic performance for  $\sim$ 8 h. Compared to previously reported III-nitride photocatalysts, the significantly improved performance is attributed to the following factors: (1) the use of the quadruple-band structure to enhance visible light absorption and water redox reactions, (2) the use of the nonplanar wafer to enhance light absorption and trapping effect, and (3) controlled p-type dopant incorporation to enhance charge carrier separation and extraction. Theoretically, the ideal multi-band photocatalytic system in the current design can potentially reach a maximum energy conversion efficiency of  $\sim$ 16% if all the incident photons above the energy bandgap can be converted to charge carriers to drive the water splitting reaction (see the ESI,† Fig. S4).<sup>65,66</sup> Therefore, such multi-band nanostructures can be further optimized to achieve a possible STH efficiency  $>$ 10%, which may include (1) optimization of the design by placing large energy gap materials on top, (2) optimization of the deposition of co-catalyst particles, (3) integration of such nanowire photocatalysts on the reflective substrate surface to further enhance light absorption, and (4) minimization of surface recombination by surface treatment or passivation. In addition, the STH efficiency may depend strongly on the light intensity, which needs to be studied in the future.

In summary, we have demonstrated wafer-level broadband InGaN nanowire photocatalysts that can significantly improve

the efficiency of direct photocatalytic overall water splitting. Such photocatalyst materials can be synthesized on low cost, large area Si wafers utilizing industry standard manufacturing processes. Therefore, their large-scale manufacturability is unquestionable in the future. Significantly, with the incorporation of suitable co-catalysts, such a unique structure can be exploited to achieve high efficiency, stable artificial photosynthesis including one-step CO<sub>2</sub> reduction to hydrocarbon fuels.<sup>41,67–79</sup>

## Methods

### Nonplanar Si surface preparation

A prime-grade polished silicon wafer was etched in 80 °C KOH solution (1.8% KOH in weight with 20% isopropanol in volume) for 30 minutes to form the micro-textured surface with Si pyramids.<sup>42</sup> After being neutralized in concentrated hydrochloric acid, surface cleaning by acetone/methanol, and native oxide removal by 10% hydrofluoric acid, the nonplanar Si wafer was loaded into the MBE chamber for the growth of InGaN nanowires.

### Molecular beam epitaxial growth of multi-band InGaN nanowires

Mg doped (p-type) InGaN nanowires, single-band or multi-band structures, were grown on as-prepared nonplanar Si substrates by plasma-assisted molecular beam epitaxy (MBE) under N-rich conditions. The growth parameters include a gallium (Ga) beam equivalent pressure of  $\sim 7 \times 10^{-8}$  Torr, a nitrogen flow rate of 1 sccm, and a plasma power of 350 W. The substrate temperature, indium (In) beam equivalent pressure (BEP), and magnesium (Mg) cell temperature were tuned to synthesize different single-band or multi-band InGaN nanowires with various p-doping and alloy concentrations. For the single-band p-GaN nanowires, the substrate temperature was 685 °C and Ga BEP was  $\sim 7 \times 10^{-8}$  Torr. The p-type doping level was tuned by using different Mg cell temperatures. For the single-band p-In<sub>0.20</sub>Ga<sub>0.80</sub>N nanowires, the substrate temperature was 675 °C, Ga BEP was  $\sim 7 \times 10^{-8}$  Torr, and In BEP was  $\sim 7.3 \times 10^{-8}$ . For single-band p-In<sub>0.27</sub>Ga<sub>0.73</sub>N nanowires, the substrate temperature was 662 °C, Ga BEP was  $\sim 7 \times 10^{-8}$  Torr, and In BEP was  $\sim 7.3 \times 10^{-8}$ . For single-band p-In<sub>0.35</sub>Ga<sub>0.65</sub>N nanowires, the substrate temperature was 640 °C with Ga BEP  $\sim 7 \times 10^{-8}$  Torr and In BEP  $\sim 3.5 \times 10^{-8}$ . For quadruple-band InGaN nanowires, the growth conditions are similar to those of the constituting single-band nanowires but with varying thicknesses for each segment. It is worth mentioning that the substrate temperature here refers to the thermocouple reading of the substrate heater, which may be different from the real substrate surface temperature, depending on the sample size, substrate holder, and mounting configuration, and therefore may vary somewhat from run to run.

### Cocatalyst nanoparticle deposition

Prior to photocatalytic water splitting experiments, metal nitride nanowires were decorated with hydrogen evolution reaction



(HER) and oxygen evolution reaction (OER) cocatalyst nanoparticles for efficient water redox reactions using the photo-deposition method. InGaN samples were put in a glass chamber with a quartz lid, which was first pumped down and then illuminated using a 300 W Xenon lamp for 20 minutes to deposit cocatalyst nanoparticles on InGaN nanowires. The deposition of Rh/CrO<sub>x</sub> core/shell structures consists of two steps, including (1) the use of 55 mL of deionized water, 11 mL of methanol, and 2 μmol sodium hexachlororhodate (Na<sub>3</sub>RhCl<sub>6</sub>, Sigma-Aldrich) for the formation of the Rh core, and (2) the use of 55 mL of deionized water, 11 mL of methanol, and 4 μmol potassium chromate (K<sub>2</sub>CrO<sub>4</sub>, Sigma-Aldrich) for the CrO<sub>x</sub> shell. The deposition of CoO<sub>x</sub> nanoparticles involves the use of 60 mL of deionized water, 6 mL of potassium iodate (KIO<sub>3</sub>, 0.01 M, Sigma-Aldrich), and 4 μmol cobalt nitrate (Co(NO<sub>3</sub>)<sub>2</sub>, Alfa Aesar).

### Photocatalytic water splitting measurements

Photocatalytic overall water splitting measurements were conducted in a vacuum chamber with a quartz lid. The measurement chamber was partially filled with 70 mL of pure water solution (pH ~ 7), which covered the InGaN photocatalysts, and was then pumped down. After evacuating the chamber, the sample was illuminated using a Xenon lamp (PE300BUV and CERMAX) together with various optical filters. With the use of an AM 1.5G filter, the light intensity is ~2339 mW cm<sup>-2</sup>, equivalent to ~23 suns, as measured at the sample position for the best performing sample. The light intensity was manually measured using a thermopile detector, which was covered using thick aluminum foil with an opening area similar to the sample size. It is important to mention that there may be ~10–20% uncertainty in the measured light intensity due to spatial variations of the light intensity of the lamp and the exact positioning of the detector and sample. The water solution was purged using argon gas for 30 minutes before any experiments. H<sub>2</sub> and O<sub>2</sub> gas was analyzed by sampling using a vacuum-tight syringe and evaluating using a gas chromatograph machine (GC-8A, Shimadzu) equipped with a thermal conductivity detector (TCD) and high purity argon as the carrier gas. Extensive photocatalytic experiments were performed on quadruple-band InGaN samples with areal sizes in the range of 0.5–1 cm<sup>2</sup> to identify the maximum STH efficiency.

### Structural and optical characterization

Room-temperature photoluminescence measurements of InGaN nanowires were performed in a homemade setup with a He–Cd 325 nm laser as the excitation source, and the emission is spectrally resolved using a SPEX spectrometer equipped with a photomultiplier tube. SEM images were recorded by employing a secondary electron detector using a Tescan MIRA3 system (15 kV) and a JEOL IT500 system (20 kV) with an EDX detector. High angle annular dark-field scanning transmission electron microscopy (HAADF-STEM) images were collected using a JEOL 3100R05 microscope operated at 300 keV in aberration corrected STEM mode with a beam convergence angle of 22 mrad and a detector collection angle of 85 mrad.

## Conflicts of interest

The authors declare no competing interests.

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